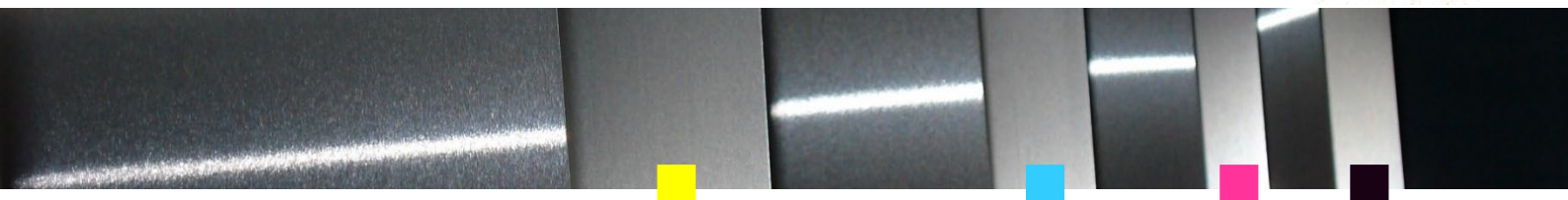


PLATEA RD1

REPLENISHER FOR DEVELOPER PLATEA D11



Ready to use replenisher for Developer PLATEA D11. Direct use.

PROPERTIES

- ✓ **DURABILITY:** Its specific formulation permits high productivity under square meters developed.
- ✓ **CLEANING:** Its dissolution capability reduces the accumulation of emulsion in the filters, rollers and developing tank.
- ✓ Non-aggressive to the anodizing layer of the plates.
- ✓ Buffered agents to minimize the aggression to the image area.
- ✓ It contains corrosion inhibitors.
- ✓ Low replenishment rate reduces the consumption and recycling.

HOW TO USE

Ready to use replenisher for Developer PLATEA D11
Fill the processor machine with developer **PLATEA D11**:

Working temperature: General set: 23°C ± 1°C (Look for specific setting on plate's TDS)

Dwell time: General set: 30" ± 5" secs (Look for specific setting on plate's TDS)

Replenisher:	RD1
Replenishment rate	50 – 70 ml/m ²
Anti-ox Standby ON	40 – 60 ml/h
Anti-ox Standby OFF	40 – 60 ml/h

** These values may vary depending on the conditions and type of the processor.

SUGGESTIONS

- ✓ Initial bath's charge must be always with developer **PLATEA D11**.
- ✓ Adequate replenishment keeps filters and circulation systems clean prolonging the life of the bath.
- ✓ Correct cleaning of the equipment will avoid contamination of the new bath and prolong the life of the processor. Clean using **LPR-5** and **LP-1**.

PACKAGING

- ✓ 20 litres
- ✓ 200 litres
- ✓ 1000 litres



V04.25

PLATEA
g r a p h i c

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